

**AMENDMENTS TO THE CLAIMS**

**This listing of claims will replace all prior versions and listings of claims in the application:**

**LISTING OF CLAIMS:**

1. (Currently Amended) An organic electroluminescent (EL) display, comprising:  
a plurality of ITO films which are disposed on a transparent substrate via an inter-layer insulating film;  
a first insulating film which is disposed between adjacent ones of said ITO films;  
an organic EL thin film deposited on said ITO films; and  
a cathode thin film deposited on said ITO films; ~~and~~ wherein:  
the first insulating film comprises a plurality of thickened portions forming insulative mask supporting layers constituting a part of or a whole of said first insulating film,  
said ~~mask supporting layers~~ thickened portions preventing a metal mask, which is used in formation of said organic EL thin film and said cathode thin film, from being in contact with a pixel portion of said transparent substrate.
2. (Original) The organic EL display according to claim 1, wherein said display uses a TFT substrate in which said ITO films and TFT layers that are disposed via said interlayer insulating film are connected to one another in an active matrix system.
3. (Currently Amended) The organic EL display according to claim ~~1~~ 19, wherein said mask supporting layers are formed by one of a resist, ceramics and an organic resin.

4. through 6. (Cancelled)

7. (Currently Amended): An organic electroluminescent (EL) display, comprising:  
a plurality of ITO films which are disposed on a transparent substrate via an inter-layer insulating film;

a first insulating film which is disposed between adjacent ones of said ITO films;

an organic EL thin film deposited on said ITO films;

a cathode thin film deposited on said ITO films; and

a plurality of insulative mask supporting layers ~~disposed on at least a part of said first~~  
protrude in a reverse tapered shape from the insulating film,

said insulative mask supporting layers preventing a metal mask which is used in formation of said organic EL thin film and said cathode thin film, from being in contact with a pixel portion of said transparent substrate.

8. (Currently Amended) The organic EL display according to claim 7, wherein said insulative mask supporting layers are formed from said first insulating ~~layer~~ film.

9. (Currently Amended) The organic EL display according to claim 7, wherein said insulative mask supporting layers are formed on said first insulating ~~layer~~ film.

10. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers are stripe-shaped.

11. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers are island-shaped.

12. (Cancelled)

13. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers have a thickness of at least 2  $\mu\text{m}$ .

14. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers have at least one portion which is either taper-shaped or ridge-shaped.

15. (Currently Amended) The organic EL display according to claim 8, wherein said insulative mask supporting layers are constituted by locally thickened portions of said first insulating ~~layer~~ film.

16. (Currently Amended) The organic EL display according to claim 9, wherein said insulative mask supporting layers are formed directly on said first insulating ~~layer~~ film.

17. (Currently Amended) The organic EL display according to claim 7, wherein said insulative mask supporting layers ~~is~~ are disposed such that a predetermined gap is maintained between a corresponding one of said ITO films and said metal mask.

18. (New) The organic EL display according to claim 1, wherein the first insulating film, including the thickened portion, is formed of a single material in a single step.

19. (New) The organic EL display according to claim 1, wherein the thickened portions of the first insulating film are formed by mask supporting layers arranged between the first insulating film and the inter-layer insulating film.

20. (New) The organic EL display according to claim 19, wherein the first insulating film completely covers the mask supporting layers.

21. (New) The organic EL display according to claim 19, wherein said mask supporting layers are stripe-shaped.

22. (New) The organic EL display according to claim 19, wherein said mask supporting layers are island-shaped.

23. (New) The organic EL display according to claim 19, wherein said mask supporting layers have a thickness of at least 2  $\mu\text{m}$ .

24. (New) The organic EL display according to claim 19, wherein said mask supporting layers have at least one portion which is either taper-shaped or ridge-shaped.

25. (New) The organic EL display according to claim 19, wherein said mask supporting layers are disposed such that a predetermined gap is maintained between a corresponding one of said ITO films and said metal mask.